

Data Sheet

M-MOS Semiconductor Hong Kong Limited

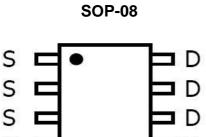
30V N-Channel Enhancement-Mode MOSFET

 V_{DS} = 30V

 $\begin{array}{l} {\sf R}_{\sf DS(ON)},\,{\sf V}_{\sf gs}@10{\sf V},\,{\sf I}_{\sf ds}@20{\sf A}\ =5.5m\,\Omega\\ {\sf R}_{\sf DS(ON)},\,{\sf V}_{\sf gs}@4.5{\sf V},\,{\sf I}_{\sf ds}@15{\sf A}\ =7.0m\,\Omega \end{array}$

Features

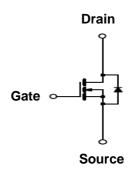
Advanced trench process technology High Density Cell Design For Ultra Low On-Resistance Fully Characterized Avalanche Voltage and Current



Top View

G

Internal Schematic Diagram



N-Channel MOSFET

Maximum Ratings and Thermal Characteristics ($T_A = 25^{\circ}C$ unless otherwise noted)

D

| Parameter | | Symbol | Limit | Unit |
|--|--------------------|-----------------------------------|------------|------|
| Drain-Source Voltage | | V _{DS} | 30 | V |
| Gate-Source Voltage | | V _{GS} | ± 20 | |
| Continuous Drain Current | | I _D | 20 | A |
| Pulsed Drain Current ¹⁾ | | I _{DM} | 80 | |
| Maximum Power Dissipation | $TA = 25^{\circ}C$ | P _D | 3 | w |
| | TA = 75°C | | 2.1 | |
| Operating Junction and Storage Temperature Range | | T _J , T _{stg} | -55 to 150 | °C |
| Junction-to-Ambient Thermal Resistance (PCB mounted) ²⁾ | | R _{θJA} | 62.5 | °C/W |

Note: 1. Repetitive Rating: Pulse width limited by the maximum junction temperature

2. 1-in² 2oz Cu PCB board



MMN4444

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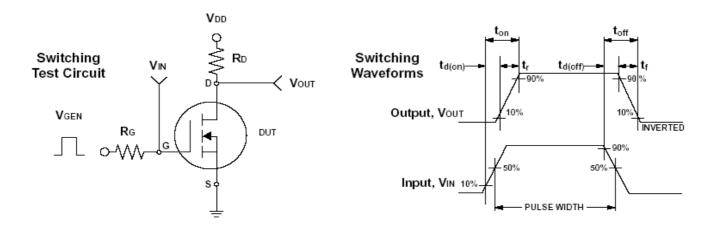
N-Channel Enhancement-Mode MOSFET

ELECTRICAL CHARACTERISTICS

| StaticDrain-Source Breakdown Voltage BV_{DSS} $V_{GS} = 0V$, $I_D = 250uA$ Drain-Source On-State Resistance $R_{DS(on)}$ $V_{GS} = 10V$, $I_D = 20A$ Drain-Source On-State Resistance $R_{DS(on)}$ $V_{GS} = 4.5V$, $I_D = 15A$ Gate Threshold Voltage $V_{GS(th)}$ $V_{DS} = V_{GS}$, $I_D = 250uA$ Zero Gate Voltage Drain Current I_{DSS} $V_{DS} = 30V$, $V_{GS} = 0V$ Gate Body Leakage I_{GSS} $V_{GS} = \pm 20V$, $V_{DS} = 0V$ | 30 | 3.9 5.7 1.7 | 5.5 | V |
|--|----|-------------------|------|------|
| Drain-Source On-State Resistance $R_{DS(on)}$ $V_{GS} = 10V$, $I_D = 20A$ Drain-Source On-State Resistance $R_{DS(on)}$ $V_{GS} = 4.5V$, $I_D = 15A$ Gate Threshold Voltage $V_{GS(th)}$ $V_{DS} = V_{GS}$, $I_D = 250uA$ Zero Gate Voltage Drain Current I_{DSS} $V_{DS} = 30V$, $V_{GS} = 0V$ Gate Body Leakage I_{GSS} $V_{GS} = \pm 20V$, $V_{DS} = 0V$ | | 5.7 | | |
| Drain-Source On-State Resistance $R_{DS(on)}$ $V_{GS} = 4.5V$, $I_D = 15A$ Gate Threshold Voltage $V_{GS(th)}$ $V_{DS} = V_{GS}$, $I_D = 250uA$ Zero Gate Voltage Drain Current I_{DSS} $V_{DS} = 30V$, $V_{GS} = 0V$ Gate Body Leakage I_{GSS} $V_{GS} = \pm 20V$, $V_{DS} = 0V$ | 1 | 5.7 | | |
| Gate Threshold Voltage $V_{GS(th)}$ $V_{DS} = V_{GS}$, $I_D = 250 \text{uA}$ Zero Gate Voltage Drain Current I_{DSS} $V_{DS} = 30 \text{V}$, $V_{GS} = 0 \text{V}$ Gate Body Leakage I_{GSS} $V_{GS} = \pm 20 \text{V}$, $V_{DS} = 0 \text{V}$ | 1 | | 70 | mΩ |
| Zero Gate Voltage Drain Current I_{DSS} $V_{DS} = 30V, V_{GS} = 0V$ Gate Body Leakage I_{GSS} $V_{GS} = \pm 20V, V_{DS} = 0V$ | 1 | 17 | 7.0 | |
| Gate Body Leakage I_{GSS} $V_{GS} = \pm 20V, V_{DS} = 0V$ | | 1.7 | 3 | V |
| | | | 1 | uA |
| Dvnamic ³⁾ | | | ±100 | nA |
| | | | | |
| Total Gate Charge Qg | | 28.48 | | nC |
| Gate-Source Charge Q_{gs} $V_{DS} = 15V$, $I_D = 20A$ $V_{GS} = 4.5V$ | | 8.08 | | |
| Gate-Drain Charge Q _{gd} | | 12.00 | | |
| Turn-On Delay Time t _{d(on)} | | 19.00 | | - ns |
| Turn-On Rise Time $t_r = 15V, R_L = 0.75\Omega$ $I_D = 1A, V_{GEN} = 10V$ | | 9.44 | | |
| Turn-Off Delay Time $t_{d(off)}$ $R_G = 3\Omega$ | | 58.84 | | |
| Turn-Off Fall Time t _f | | 8.68 | | |
| Input Capacitance C _{iss} | | 3234.38 | | pF |
| Output Capacitance C_{oss} $V_{DS} = 15V, V_{GS} = 0V$ f = 1.0 MHz | | 456.44 | | |
| Reverse Transfer Capacitance C _{rss} | | 329.12 | | |
| Source-Drain Diode | | | | |
| Max. Diode Forward Current I _s | | | | А |
| Diode Forward Voltage V_{SD} $I_S = 1A, V_{GS} = 0V$ | | | | |

Note: Pulse test: pulse width <= 300us, duty cycle<= 2%

3. Guaranteed by design; not subject to production testing





Notice

1. Specification of the products displayed herein are subject to change without notice. Continuous development may necessitate changes in technical data without notice. M-MOS Semiconductor Sdn. Bhd. or anyone on its behalf, assumes no responsibility or liability for any errors or inaccuracies.

2. Stresses beyond those listed under "Absolute Maximum Ratings" may cause permanent damage to the device. These are stress ratings only, and functional operation of the device at these or any other conditions beyond those indicated in the operational sections of the specifications is not implied. Exposure to absolute maximum rating conditions for extended periods may affect device reliability.